

Evactron® 45

Try the Evactron®
Process in your lab, free,
[shipping charges apply]
for 30 days by placing an
evaluation PO by
January 15, 2008.

For removal of atmospheric molecular contamination,
oils and hydrocarbons

IN SEMS AND FIBS



NEW!

Evactron® 45 De-Contaminator

XEI SCIENTIFIC introduces our exciting new Evactron® 45 De-Contaminator (D-C) for cleaning scanning electron microscopes. We're pushing the frontiers electron microscope cleaning technology to improve resolution and imaging time for 21st century needs.

Evactron® D-C cleaning uses a unique, cutting edge process for remote plasma production of oxygen radicals that flow downstream through your system, removing hydrocarbons.

These new user friendly Evactron® D-C models optimize remote plasma cleaning perfectly to the needs of the user.

*Gentle. Fast.
Convenient and
Effective Cleaning*

- Easy to operate and setup
- Start cleaning by using vent and evacuation controls for chamber.
- Uses preset pressure, power, and time settings from front panel or computer interface
- Uses air, no special gases needed
- Plasma and nitrogen purge cleaning can be combined in cycles for maximum cleaning efficiency
- Advanced plasma detection logic
- Cleaning and error logs record cleaning history and aids trouble shooting
- Rackmounted
- Electronic Chassis: H 3.5" x W 19.5" x D 7"
- RF Power: 5 - 20 Watts at 13.566 MHz
- KF 40 vacuum mounting flange
- 100-240 VAC 50/60 Hz input



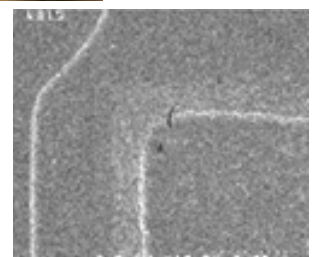
XEI SCIENTIFIC, INC



1755 EAST BAYSHORE RD, SUITE 17
REDWOOD CITY, CA 94063
MAIN 1.650.369-0133 1.800.500.0133
FAX 650.363.1659
HTTP://EVACTION.COM/ INFO@EVACTION.COM
SALES@EVACTION.COM 1.415.566.5774



Unwanted Artifact



After Evactron Cleaning